OCT 2 4 2003 IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

RADF Applicant: Seetharaman Sridhar, et al.

TI-31408 Docket No:

Serial No:

10/005,785

Conf. No: 1353

Examiner:

Jermele M. Hollington

Art Unit:

2829

Filed:

11/08/2001

For:

PROCESS TO IMPROVE NWELL-NWELL ISOLATION WITH A BLANKET LOW DOSE

HIGH ENERGY IMPLANT

## **ELECTION**

**Commissioner For Patents** P.O. Box 1450 Alexandria, VA 22313-1450 MAILING CERTIFICATE UNDER 37 C.F.R. § 1.8(a)

I hereby certify that the above correspondence is being deposited with the U.S. Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450 on 10-20-03

Dear Sir:

This election is offered in response to the Examiner's restriction requirement mailed September 26, 2003.

Applicants hereby elect to pursue Group I of Claims 1-2, drawn to integrated circuit structure, without traversing the Examiner's restriction requirement. Applicant further elects species I drawn to claim 1 without traversing the Examiner's restriction.

Respectfully submitted,

Peter K. McLarty

**Attorney for Applicants** 

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